

Spanish Nanolithography Strategy Session **Jornada de estrategia en Nanolitografía en España**

Date: 26th May 2009

Place: Professors Room (first floor) of the Science Faculty of the University of Zaragoza. Campus in the San Francisco Square, in Zaragoza.

10-10:10 h Opening and presentation of the Spanish Nanolithography Network (Session in Spanish/English)

J.M. De Teresa (ICMA)

10:10h – 11:00h. Similar experiences in foreign countries (Session in English)

- Thomas Swahn – Micro and Nano Fabrication Network (Sweden)
- Hugues Garnier - Technological Platform LAAS-CNRS (France)

11:00-11:30h Discussion (Session in English)

11:30-12:00 Coffee

12-12:45h Spanish ICTS Presentation (Singular Scientific and Technological Infrastructures)

- Emilio Lora Tamayo - CNM
- Enrique Calleja - ISOM

12:45 -13:45 h. MICINN Presentation (Ministry of Science and Innovation)

- Francisco Herrada – Area Director, Vice-Director-General of Scientific and Technological Infrastructures Planning Department of the Ministry of Science and Innovation (Spanish Government)
- Pedro Serena – collaborator of the of Nanoscience area in the Ministry of Science and Innovation

13:45 -14:30h Discussion

14:30-16:00h Lunch

16.00-17.30h Nanolithography Infrastructures in Spain (10min each)

- José Ignacio Martín (Oviedo University, Asturias)
- José Rivas (INL, Braga)
- Ricardo García (IMM, CSIC, Madrid)
- Albert Romano (IN2UB, Univ. Barcelona)
- José María Pitarque (CICNanoGUNE, Basque Country)
- Bausells (CNM, Barcelona)
- Santos Merino (Tekniker, Basque Country)
- Ricardo Ibarra (INA, Univ. Zaragoza)
- Clivia Sotomayor (CIN2, ICN-CSIC, Barcelona)

17.30h – 17:35h Closing

Goal of the Session : Obtain an overall view of the current situation of the Nanolithography in Spain, counting with the experiences of Sweden and France and within the Spanish centres and discussing on possible future initiatives in the field.